



UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, Virginia 22313-1450
www.uspto.gov

APPLICATION NO.	ISSUE DATE	PATENT NO.	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/574,122	11/10/2009	7615557	078503.0105	5546

21003 7590 10/21/2009
BAKER BOTTS L.L.P.
30 ROCKEFELLER PLAZA
44TH FLOOR
NEW YORK, NY 10112-4498

ISSUE NOTIFICATION

The projected patent number and issue date are specified above.

Determination of Patent Term Adjustment under 35 U.S.C. 154 (b) (application filed on or after May 29, 2000)

The Patent Term Adjustment is 152 day(s). Any patent to issue from the above-identified application will include an indication of the adjustment on the front page.

If a Continued Prosecution Application (CPA) was filed in the above-identified application, the filing date that determines Patent Term Adjustment is the filing date of the most recent CPA.

Applicant will be able to obtain more detailed information by accessing the Patent Application Information Retrieval (PAIR) WEB site (<http://pair.uspto.gov>).

Any questions regarding the Patent Term Extension or Adjustment determination should be directed to the Office of Patent Legal Administration at (571)-272-7702. Questions relating to issue and publication fee payments should be directed to the Application Assistance Unit (AAU) of the Office of Data Management (ODM) at (571)-272-4200.

APPLICANT(s) (Please see PAIR WEB site <http://pair.uspto.gov> for additional applicants):

Axel Bouchon, Koln, GERMANY;
Nicole Diedrichs, Velbert, GERMANY;
Achim Hermann, Dusseldorf, GERMANY;
Klemens Lustig, Wuppertal, GERMANY;
Heinrich Meier, Wuppertal, GERMANY;
Josef Pernerstorfer, Hilden, GERMANY;
Elke Reissmuller, Wuppertal, GERMANY;
Jean De Vry, Stolberg, GERMANY;
Muneto Mogi, Ibaraki-ken, JAPAN;
Klaus Urbahns, Lund, SWEDEN;
Takeshi Yura, Nara-ken, JAPAN;
Hiroshi Fujishima, Nara-ken, JAPAN;
Masaomi Tajimi, Aichi-ken, JAPAN;
Noriyuki Yamamoto, Osaka-fu, JAPAN;
Hiroaki Yuasa, Kyoto, JAPAN;
Jang Gupta, Dusseldorf, GERMANY;
Yasuhiro Tsukimi, Hyogo-ken, JAPAN;
Fumihiko Hayashi, Tokyo, JAPAN;